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Cynthia Standiford
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INFORMATION DISCLOSURE DOCUMENT

Enclosed is a list and copies of references considered by Applicant to be pertinent in the examination of the above-identified patent application.

Applicant submits this Information Disclosure Statement in accordance with the duty of disclosure under 37CFR §1.56 and 1.97-1.98. This Statement is filed in accordance with 37 CFR §1.97(b)(3), prior to issuance of a First Office.

Applicants(s) submitted herewith patents, publications or other information of which they are aware, which they believe may be material to the examination of this application and in respect

of which there my be a duty to disclose in accordance with 37 CFR 1.56. While this Information Disclosure Statement may be "material" pursuant to 37 CFR 1.56 it is not intended to constitute an admission that any patent, publication or other information referred to therein is "Prior art" for this invention unless specifically designated as such. In accordance with 37 CFR 1.97(b) the filing of this Information Disclosure Statement shall not be construed to mean that a search has been made or that no other material information as defined in 37 CFR 1.56 (a) exists.

Respectfully submitted,

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(use as many sheets as necessary)

Complete if Known			
Application Number	10/705,687		
Filing Date	November 10, 2003		
First Named Inventor	Mahendra Sunkara		
Art Unit			
Examiner Name			
Attorney Docket Number	AD138/2001		

U.S. PATENT DOCUMENTS Name of Patentee or Pages, Columns, Lines, Where Relevant Publication Date Document Number Examine Cite MM-DD-YYYY Applicant of Cited Document Passages or Relevant Initials* Number-Kind Code² (FA) Figures Appear /EMJ/ US 5,725,674 March 10, 1998 Moustakas et al. Throughout /EMJ/ US 6 051 849 April 18, 2000 Davis et al. Throughout /EMJ/ Westwater et al. Throughout US 5,858,862 January 12, 1999 /EMJ/ October 1999 Russell et al. Throughout US 5,962,863 7EMJ/ Throughout US 5,381,753 January 17, 1995 Okaiima et al. /EMJ/ Throughout Wolfe et al. US 6,063,246 May 16, 2000 /EMJ/ Throughout US 4.886.683 December 12, 1989 Hoke et al. /EMJ/ US 5,334,296 August 2, 1994 Henkens et al Throughout /EMJ/ US 6,033,866 March 7, 2000 Guo et al. Throughout /EMJ/ July 13, 1999 US 5,922,183 Rauh throughout /EMJ/ /EMJ/ US 8,906,228 June 20, 2002 Sharma et al. Throughout US 5.120.707 June 1992 Maxfield et al. Throughout /EMJ/ US 4,939,308 July 1990 Maxffield et al. Throughout

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Examiner Signature /Edward M. Johnson/ (06/24/2007)	Date Considered
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 809. Draw line through citation if not in conformance and not considered, include copy of this form with reat communication to applicant. **Applicants unique citation of estignation number (options), **See Knots Code of USEP 07 bears (Document and Per 901.04. **Einstein College that session the document, by the wheteer cost (PMPC Standard Standar

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